



CHECKLIST

United Nations/Japan Long-term Fellowship Programme “Doctorate in Nano-Satellite Technologies (DNST)”

The following documents should be sent to the United Nations Office for Outer Space Affairs as indicated in the application form:

- Application form.** Duly completed by the applicant in two copies and certified on behalf of the nominating institution by the certifying officer*.
- Diploma certificates.** Two official copies of the education certificate(s) of Bachelor’s, Master’s or higher degrees and the official translation of these documents in English.
- Academic transcripts.** Two official copies of academic transcripts indicating the subjects and examination grades (marks) received in each subject in undergraduate and higher courses and the official translation of these documents in English. The transcripts have to be sealed by the President or Dean of the Institution from which the applicant graduated.
- Diploma or certificate of competence in the language of the fellowship programme.** If the official language of the applicant's country is different from the language of the fellowship programme, a diploma, certificate or proof of competence in the language shall be provided. This diploma/certificate shall be issued by an accredited language institution or by the local UNDP upon satisfactory establishment of the applicant's competence in the language concerned.
- Curriculum vitae.** Signed and dated by applicant.
- 4 Photographs** (4cm high x 3cm wide).

The three (3) completed Referee reports should be sent to the United Nations Office for Outer Space Affairs by the referees themselves. One of the referees should be the employment or study supervisor of the applicant.

- Referee report 1**
- Referee report 2**
- Referee report 3**

* The certifying officer shall not be lower in rank than the Head of the applicant's Department, Institution or Ministry. The certifying officer attests to the accuracy of the information provided by the applicant in his/her application form and the bona fide status of the applicant in his/her institution.